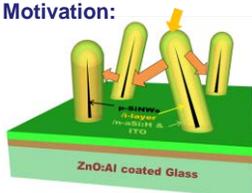


**Soumyadeep MISRA, Linwei YU, Martin FOLDYNA and Pere ROCA i CABARROCAS**  
 LPICM-CNRS, Ecole Polytechnique, 91128 Palaiseau, France

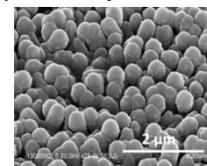
**Abstract:** Owing to their enhanced light trapping and anti-reflection effects, silicon nanowires (SiNWs) provide an active research platform for a new generation of cost-effective and efficient solar cells. By optimizing the density of nanowires and depositing amorphous silicon (a-Si:H) on top of them, stable radial junction PIN devices with efficiencies ~8% have already been realized and there is still room for improvement. For instance, by modifying the SiNW/a-Si:H interface, an open circuit voltage as high as 0.9 V has been achieved. Also, increasing the band gap of the window layer is found to be effective for blue-response enhancement. Modeling of equivalent structure with a-Si:H nanowires by rigorous coupled wave analysis method shows that short circuit current density can be improved up to 20 mA/cm<sup>2</sup> and changing the active material to a lower band gap material, e.g.,  $\mu$ c-Si:H or a-SiGe:H allows to take the advantage of broader solar spectrum.

### Motivation:

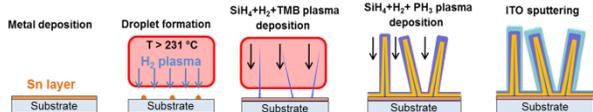


- Excellent light trapping and anti-reflection effect.
- Decouples light absorption and carrier collection direction.
- Lower material consumption, 100 nm is the typical thickness for a-Si:H radial junction cells compared to 250 nm used on the textured substrates.
- Improved stability against light soaking.
- Highest efficiency of 9.2% ( $J_{sc}$  calibrated with EQE).

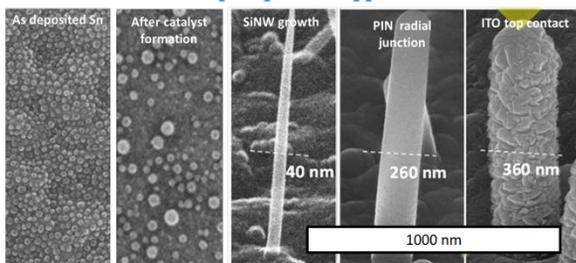
### Complete radial junction with ITO



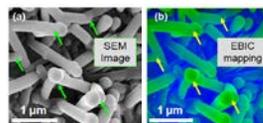
### Fabrication procedure:



### One-pump-down approach



### Feasibility of making a device on randomly tilted nanowire array:

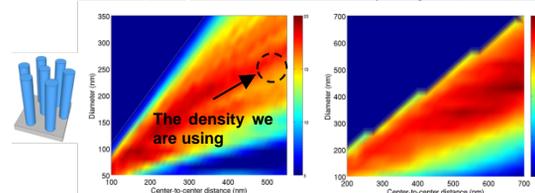


EBIC mapping shows that high quality and **robust junction** is feasible over random plasma-assisted VLS-grown SiNWs.

### Modelling of radial junctions:

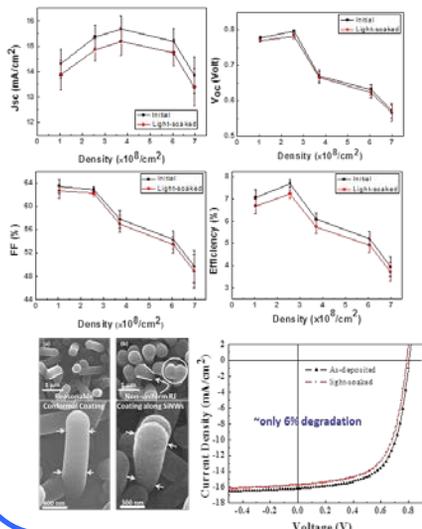
Theoretical short circuit current density can be calculated by 3D rigorous coupled-wave analysis by using the formula:  $J_{sc} = e \int E(A(E)N(E)dE$

For 1  $\mu$ m long a-Si:H nanowires      For 1  $\mu$ m long c-Si nanowires

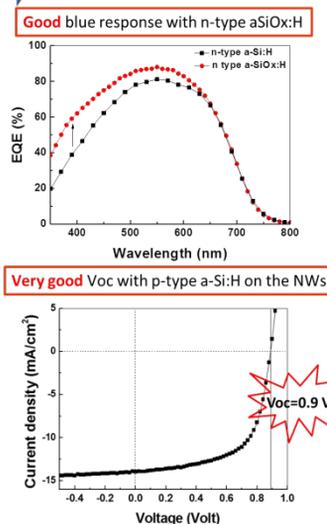


### Results:

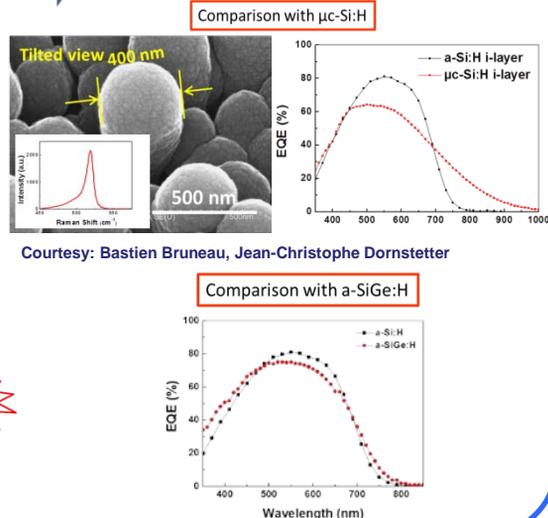
#### Impact of SiNW density on cell performance



#### How to improve further



#### Attempts to change the absorber material



Courtesy: Bastien Bruneau, Jean-Christophe Dornstetter

**Future work:** Improvement of the NIP cells, Improving the bottom cell, realization of tandem structure.

References: [1] S. Misra, L. Yu, M. Foldyna, P. Roca i Cabarrocas, *SOLMAT*, 118, 90-95 (2013), [2] S. Misra, L. Yu, W. Chen, P. Roca i Cabarrocas, *The Journal of Physical Chemistry C*, 117, 17786 (2013) [3] S. Misra, L. Yu, M. Foldyna, P. Roca i Cabarrocas, *Journal of Physics D: Applied Physics*, 47, 393001 (2014).

Contact: soumyadeep.misra@polytechnique.edu